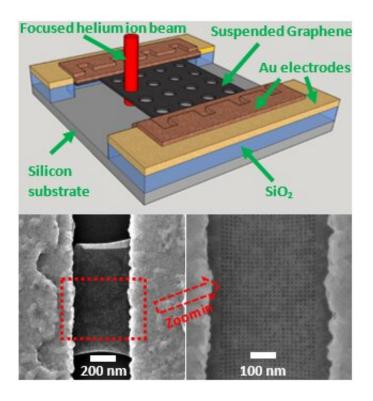


New 'brick' for nanotechnology: Graphene nanomesh

April 20 2020



Graphene nanomesh. Credit: Hiroshi Mizuta, JAIST

Researchers at Japan Advanced Institute of Science and Technology (JAIST) have successfully fabricated suspended graphene nanomesh in a large area by helium ion beam microscopy. Six nm diameter nanopores were uniformly patterned on the 1.2 um long and 500 nm wide suspended graphene. By systematically controlling the pitch (nanopore's center to nanopore's center) from 15 nm to 50 nm, a series of stable



graphene nanomesh devices were achieved. This provides a practical way to investigate the intrinsic properties of graphene nanomesh towards applications for gas sensing, phonon engineering, and quantum technology.

Graphene, with its excellent electrical, thermal and <u>optical properties</u>, is promising for many applications in the next decade. It is also a potential candidate instead of silicon to build the next generation of electrical circuits. However, without a bandgap, it is not straightforward to use graphene for field-effect transistors (FETs). Researchers tried to cut a graphene sheet into a small piece of graphene nanoribbon and observed the bandgap opening successfully. However, the current of graphene nanoribbons is too low to drive an integrated circuit. In this case, the graphene <u>nanomesh</u> is pointed out by introducing periodic nanopores on the graphene, which are also considered as a very small graphene nanoribbon array.

A research team led by Dr. Fayong Liu and Professor Hiroshi Mizuta has demonstrated, in collaboration with researchers at the National Institute of Advanced Industrial Science and Technology (AIST), that large area suspended graphene nanomesh is quickly achievable by helium ion beam microscopy with sub-10 nm nanopore diameter and well-controlled pitches. Compared to slow speed TEM patterning, the helium ion beam milling technique overcomes the speed limitation, and meanwhile provides a high imaging resolution. With the initial electrical measurements, it was found that the thermal activation energy of the graphene nanomesh increased exponentially by increasing the porosity of the graphene nanomesh. This provides a new method for bandgap engineering beyond the conventional nanoribbon method. The team plans to continue exploring graphene nanomesh towards the application of phonon engineering.

"Graphene nanomesh is a kind of new 'brick' for modern micromachine



systems. Theoretically, we can generate many kinds of periodical patterns on the original suspended graphene, which tunes the property of the device to the direction for a specific application, in particular nanoscale thermal management," says Prof. Hiroshi Mizuta, the Head of Mizuta Lab. The Mizuta lab is currently developing the electrical and thermal properties of graphene-based devices for <u>fundamental physics</u> and potential applications such as gas sensors and thermal rectifiers. The aim is to use <u>graphene</u> to build a greener world.

More information: Fayong Liu et al, Conductance Tunable Suspended Graphene Nanomesh by Helium Ion Beam Milling, *Micromachines* (2020). <u>DOI: 10.3390/mi11040387</u>

Provided by Japan Advanced Institute of Science and Technology

Citation: New 'brick' for nanotechnology: Graphene nanomesh (2020, April 20) retrieved 25 April 2024 from <u>https://phys.org/news/2020-04-brick-nanotechnology-graphene-nanomesh.html</u>

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